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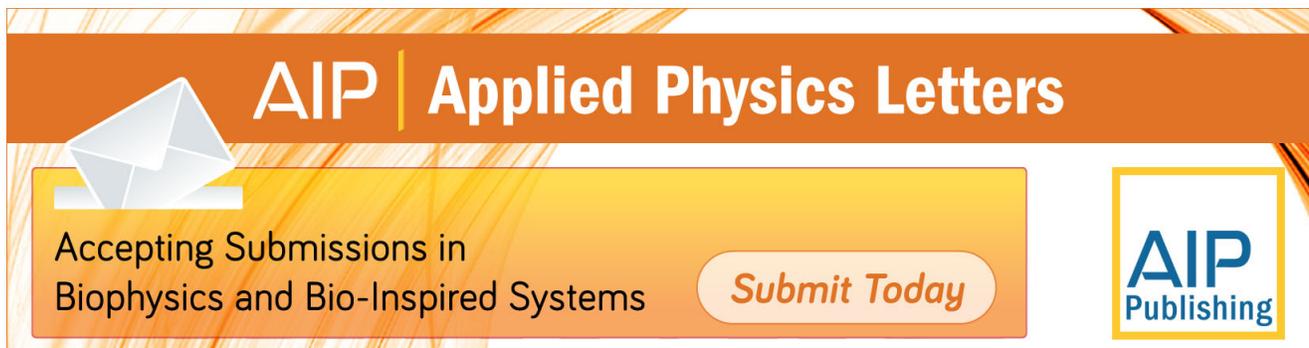
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Strong coupling between Rhodamine 6G and localized surface plasmon resonance of immobile Ag nanoclusters fabricated by direct current sputtering

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We made clean silver nano-clusters (AgNCs) on glass substrates by DC magnetron sputtering of a high purity Ag target in a high vacuum chamber. The AgNCs film shows strong localized surface plasmon resonance (LSPR) due to the coupling among Ag nanoparticles in the AgNCs and the coupling between AgNCs. The LSPR indicates strong coupling with Rhodamine 6G (R6G) adsorbed on the AgNC surface, which enhances the R6G absorption intensity and broadens the absorption wavelength range. This result promotes plasmonic nanoparticles to be better used in solar cells. © 2013 AIP Publishing LLC. [<http://dx.doi.org/10.1063/1.4801633>]

Ag nanoparticles (AgNPs) produce a sharp and strong localized surface plasmon resonance (LSPR),¹ if given a proper visible light excitation. Recently, plasmonic enhancement of the efficiencies of solar cells^{2–5} and organic light emitting diodes^{6,7} is drawing tremendous interest. Promoting light absorption^{8,9} is one of the key issues improving the solar cell efficiency. Historically, most plasmonic nanoparticles have been synthesized with colloidal chemical methods¹⁰ or monolayer assembly by Langmuir-Blodgett technique.¹¹ Other methods are based on lithographic techniques such as electron beam¹² or nanosphere lithography.¹³ Previous work has also demonstrated that when two or more AgNPs are brought into proximity, the LSPR of individual AgNPs couples each other, resulting in enhanced LSPR intensity and modulated peak position,¹⁴ which would benefit us to better use of LSPR. But again, most reported coupled plasmonic particles were produced by chemical seeding techniques¹⁵ or electron beam lithography.¹⁶ Magnetron sputtering¹⁷ is a very common technology to produce nanoparticles free from chemical residues. The clean nanoparticles allow the probe molecules to be directly adsorbed on the nanoparticle surface, which is favorable for strong coupling between the LSPR and the excitons of the adsorbed molecules to take place. Strong coupling benefits energy transfer and charge transfer and hence could enhance the energy transfer efficiency in solar cells.

Our group has previously produced AgNPs on silicon substrates by DC sputtering and studied their surface enhanced Raman scattering (SERS) enhancement properties using Rhodamine 6G (R6G).¹⁸ Most AgNPs on silicon substrates isolated from each other to form three dimensional nanostructures. These unique structures had high SERS activity and were successfully applied to detect carbon deposition and cathode thin film materials used in solid oxide fuel

cells.¹⁹ For the current work, AgNPs were deposited on glass substrates by DC sputtering. The morphology of the AgNPs has been successfully changed from “isolated row” to “nanocluster” and then to thin continuous smooth films with sputtering time increase from 40 s to 300 s at sputtering power of 10 W. The nanoclusters showed the strongest LSPR and the strongest coupling with the excitons of R6G. This study provides useful information for improving efficiency of solar cell and organic light emission diodes.

The AgNPs films were deposited onto glass substrates by a 10 W DC sputtering level using a high purity Ag target (99.995%) with a plasma generated by ultra-purity Ar (99.999%) at sputtering times of 40, 100, 180, and 300 s. The base pressure in the vacuum chamber was about 2×10^{-6} mbar. During sputtering, the flow of Ar was 80 sccm, and the working pressure was maintained at 2.2×10^{-2} mbar. The substrates themselves were not heated during sputtering. After deposition the samples were removed from the vacuum chamber and immersed in R6G solution with a concentration of 10^{-5} M for 3 h. The morphology and uniformity of the films were characterized by atomic force microscopy (AFM). Extinction spectra were measured by an Ocean Optics HR4000Cg-UV-NIR spectrometer.

AFM images of AgNPs deposited on glass substrates by sputtering at 10 W for 40, 100, 180, and 300 s (named 10W40s, 10W100s, 10W180s, and 10W300s in the following) are shown in Figs. 1(a)–1(d), respectively. The AgNPs of the 10W40s sample are ellipsoids with size dispersion. Some small ones are about 10 nm, and the largest can reach 40 nm. The long axis of most particles is roughly along the same direction such that “nano-row”-like structures are formed, with spaces between rows. The characteristic features of the AgNPs deposited at sputtering time of 100 s are “nanoclusters,” composed of two or three small silver nanospheres with an average size around 16 nm each. The preferential direction is still obvious. When the sputtering time was increased to longer than 180 s, there were no obvious

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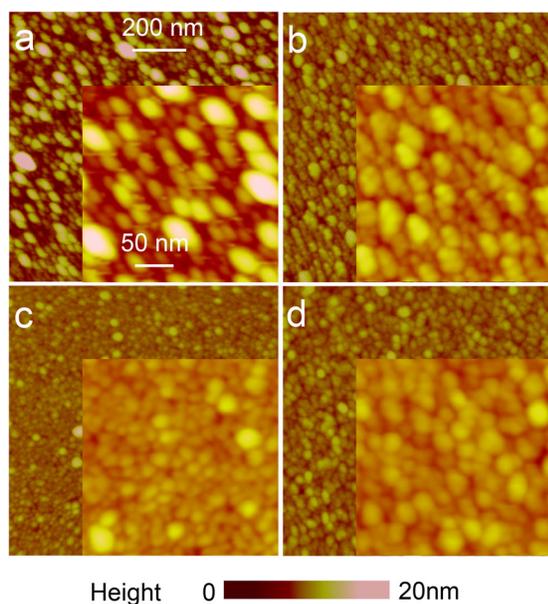


FIG. 1. AFM images of AgNPs samples fabricated at DC sputtering power of 10 W for sputtering times of (a) 40 s, (b) 100 s, (c) 180 s, and (d) 300 s. The scale bars are same for the four figures.

clusters on the surface. The AgNPs were spherical with average size around 20 and 30 nm for sputtering for 180 and 300 s, respectively. The AgNPs connected tightly to form continuous thin films with smooth surface, which is much different from AgNPs on silicon surface.¹⁸

The growth of AgNPs by sputtering has been widely studied.²⁰ It follows a Volmer-Weber growth mode:²¹ in the initial state, the Ag atoms reaching the substrate form isolated nuclei on the surface. After the nuclei formation process, the subsequently reached atoms diffuse on the surface and join the formed nuclei to promote their growth. This is nuclei growth. As the sputtering time increases, the nano-clusters coalesce into a continuous film.²² We found the right fabrication parameters and clearly recorded this process. In our experiment, we chose 10 W as the sputtering power level, and when sputtering for 40 s, we observed the isolated nuclei. Most particles are ~ 10 nm, and a few larger ones have a size of about 40 nm, which are in fact grown nuclei. Even though some parts of the glass surface are still blank with gaps between the 10-nm-AgNPs, the subsequently arrived Ag atoms do not form nuclei in the gaps; instead, they diffuse across the surface to join the formed nuclei and promote the nuclei to grow into clusters. When sputtering for 100 s, a clear image of the grown clusters was obtained, as shown in Fig. 1(b). The formed clusters are composed of two or three nanospheres, while the gaps between adjacent clusters are very small. Such structure is very favorable for producing strong LSPR due to the coupling among the AgNPs in the clusters and the coupling between the AgNCs. It indeed owns strong LSPR and will be demonstrated later. The deposited clusters changed the surface energy such that the subsequently reached atoms would be easily trapped at the gaps and form nuclei. Therefore, when the sputtering time was increased to 180 s, the surface became smooth and no clusters could be seen, which is shown in Fig. 1(c). As sputtering time was

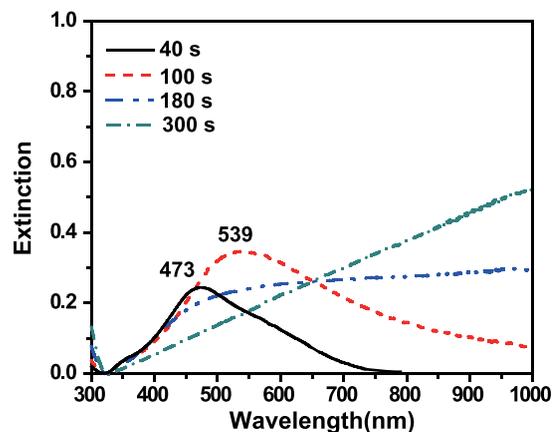


FIG. 2. The extinction spectra of AgNPs deposited on glass substrates by sputtering at 10 W for times of 40, 100, 180, and 300 s.

increased further to 300 s, the particles grow further to ~ 30 nm due to the Ostwald ripening process.²³

The extinction spectra of AgNP films with different sputtering times are shown in Fig. 2. The 10W40s sample had an asymmetric LSPR peak at 473 nm, and the LSPR peak shifted to 539 nm with a stronger intensity as the sputtering time was increased to 100 s. When the sputtering time was further increased to 180 s, a broad band that covered the whole range of the measurement was obtained. This band had a shoulder around 539 nm. Compared with that of the 10W100s sample, the extinction spectrum of the 10W180s sample showed higher absorption at longer wavelength range (670–1000 nm) but lower intensity at shorter wavelength range (300–670 nm). When the sputtering time was increased to 300 s, the absorption spectrum turned into a straight line.

The extinction spectra of the samples are related to the morphology of the sputtered AgNPs. The average particle size of the 10W100s sample is 16 nm, and the corresponding LSPR peak is located at 539 nm. Comparatively, Futamata²⁴ reported that isolated 16 nm AgNPs gave an absorption peak at 397 nm which shifted to longer wavelength when the AgNPs were brought closer to each other. For example, in the case of three AgNPs with 1-nm gaps between them, the LSPR shifted to 600 nm, while with a 2 nm-gap, the LSPR peak was found at 510 nm. Based on the above report and the AFM images shown in Figs. 1(a) and 1(b), the observed LSPR peaks at 473 nm and 539 nm in this study were due to the coupling among AgNPs in a cluster and the coupling between AgNCs. Especially for the 10W100s sample, the gaps between clusters are very narrow. These narrow gaps are very important and are hotspots which own huge electric field due to the coupling between the isolated AgNCs.

As shown in Fig. 1(c), the AgNPs in the 10W180s sample had an average particle size of 20 nm. Since the nanoparticles connected one by one to form smooth continual film the LSPR in fact turned into surface plasmon (SP), therefore the extinction intensity was reduced and there was no absorption peak in the absorption spectrum but a shoulder at 539 nm. Sputtering for 300 s, the particle size increased to 30 nm; however, due to the connection of AgNPs, the film turned into 2-dimensional continual films. Reflection from the films seriously interfered with the measurement.

to three factors. First, due to the continuity of the formed AgNP thin film the LSPR was in fact turned into SP, which was much weaker than the LSPR. Second, due to the coupling among AgNPs the SP was in the infrared region; therefore, the excitons of the R6G molecules could not resonantly couple with the plasmons. Chen *et al.*²⁸ reported that when the wavelength of LSPR was much longer than that of the molecular absorption, the coupling became very weak. In this situation, the role of the molecules was only changing the dielectric constant of the nano environment surrounding metal nanocrystals. The absorption peak of R6G was just overlapped on the right side of the LSPR of the 10W300s AgNPs thin film; therefore, no strong coupling took place. Third, the reduced surface area in the AgNP samples with longer sputtering time might promote the adsorption of R6G in the form of dimers, which would decrease the probability of coupling. For a specific R6G concentration, the amount of dimers would theoretically increase if the specific surface area of total AgNPs was reduced. According to Fig. 1, the 10W100s AgNCs have the largest surface area, and with the sputtering time increase, the roughness was reduced and the total specific surface area was reduced; therefore, the amount of dimers should have increased. When 10^{-5} M R6G molecules were loaded onto Ag film, it was previously reported²⁶ that the absorption peak of H-dimer was at 506 nm, while the peaks of monomers and J-dimers were at 537 and 568 nm, respectively. In our experiment, the H-dimer absorption peak is near 506 nm, which is consistent with what was reported in the literature. In contrast, the monomer absorption peak is at 553 nm, which is likely due to the mixed absorption of the J-dimers and the monomers. J-aggregates were previously reported to be strongly³¹ or coherently³² coupled with the LSPR of AgNPs, but there are no reports about the strong coupling between H-dimers with LSPR. Therefore, the coupling between SP and the excitation of dimers should be weaker than that of LSPR with the excitons of R6G monomers; hence, the coupling decreased gradually when the sputtering time was longer than 180 s.

For comparison, we also made AgNPs thin film by evaporation in vacuum and tuned the LSPR of the AgNPs to 473 nm, which is at the same wavelength of the 10W40s sample. After loading of 10^{-5} M R6G, the extinction spectrum is shown in Fig. 4(b). The three coupled peaks are located at 430, 516, and 549 nm. It is clear that the coupling between AgNPs made by vacuum evaporation is much weaker than the counterpart made by vacuum sputtering. Therefore, the AgNCs made by vacuum sputtering indeed own very strong LSPR and not only improve the absorption intensity but also broaden the absorption wavelength range of R6G. This technology can be optimized to promote plasmonic nanoparticles to be better used in solar cells.

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